IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

POWER OF ATTORNEY BY ASSIGNEE

Under the provisions of 37 C.F.R. § 3.71, H.C. STARCK INC., the undersigned assignee of record of the entire interest in the pending patent applications listed on the attached Schedule A by virtue of assignments filed in respective applications elects to conduct the prosecution of the application/maintenance of the patents to the exclusion of the inventor(s). The undersigned hereby declares that he has reviewed the above-referenced assignment and hereby declares that, to the best of his knowledge, title is in the Assignee, and further declares that all statements made herein of his own knowledge are true and that all statements made on information and belief are believed to be true. The assignee hereby revokes any previous powers of attorney and appoints the following to prosecute the application(s)/maintain the patent(s) and transact all business in the Patent and Trademark Office connected therewith:

Practitioners associated with Customer Number 23517

The above-identified attorneys are now to be indicated to have the full power to prosecute the applications listed in the attached Schedule A before the U.S. Patent and Trademark Office.

> ASSIGNEE H.C. STARCK INC.

Date: 3/11/2012

By: Robert K. Sarafian

Vice President, General Counsel and Secretary H.C. Starck Inc.

45 Industrial Place Newton, MA 02461

SCHEDULE A

H.C. Starck Inc. - Pending Patent Applications

| Application No. | Title | New Atty. Docket No. |
|-----------------|---|----------------------|
| 11/216,498 | FINE GRAIN NIOBIUM SHEET VIA INGOT METALLURGY | HCS-016/7309682001 |
| 13/340,973 | MOLYBDENUM TUBULAR SPUTTERING TARGETS WITH UNIFORM GRAIN SIZE AND TEXTURE | HCS-017C1/7309663001 |
| 12/853,615 | LIQUID COOLED GLASS METAL ELECTRODE | HCS-018/7309672001 |
| 13/301,066 | REFRACTORY METAL POTS | HCS-019DV/730969500 |
| 12/915,781 | NIOBIUM BASED ALLOY THAT IS RESISTANT TO AQUEOUS CORROSION | HCS-020DV/730970500 |
| 12/090,919 | METHODS OF MAKING MOLYBDENIUM TITANIUM SPUTTERING PLATES AND TARGETS | HCS-021B/7309732001 |
| 12/917,668 | METHODS OF MAKING MOLYBDENUM TITANIUM SPUTTERING PLATES AND TARGETS | HCS-021DV/730973500 |
| 12/109,765 | TANTALUM BASED ALLOY THAT IS RESISTANT TO AQUEOUS CORROSION | HCS-022/7309742001 |
| 12/915,681 | TANTALUM BASED ALLOY THAT IS RESISTANT TO AQUEOUS CORROSION | HCS-022DV/730974500 |
| 13/124,814 | TANTALUM BASED ALLOY THAT IS RESISTANT TO AQUEOUS CORROSION | HCS-023/7309752001 |
| 11/653,816 | HIGH DENSITY REFRACTORY METALS & ALLOYS SPUTTERING TARGETS | HCS-024/7309892001 |
| 10/593,809 | METHODS OF FORMING ALPHA AND BETA TANTALUM FILMS WITH CONTROLLED AND NEW MICROSTRUCTURES | HCS-026/7309862001 |
| 12/256,609 | REFRACTORY METAL-DOPED SPUTTERING TARGETS, THIN FILMS PREPARED THEREWITH AND ELECTRONIC DEVICE ELEMENTS CONTAINING SUCH FILMS | HCS-028/7309762001 |